03500.014179

PATENT APPLICATION

| IN THE UNITED STATES PATE | NT AND TRADEMARK OFFICE |
|-----------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|-------------------------------------------------------|
| In re Application of: YOICHI ANDO ET AL. Application No.: 09/722,454 | Examiner: M. Santiago Group Art Unit: 2879 |
| Filed: November 28, 2000 | ;) |
| For: METHOD FOR MANUFACTURING ELECTRON BEAM DEVICE, METHOD FOR MANUFACTURING IMAGE FORMING APPARATUS, ELECTRON BEAM DEVICE AND IMAGE FORMING APPARATUS MANUFACTURED THOSE MANUFACTURING METHODS, METHOD AND APPARATUS FOR MANUFACTURING ELECTRON SOURCE AND APPARATUS FOR MANUFACTURING IMAGE FORMING APPARATUS | FAX RECEIVED JUL 2003 TECHNOLOGY 2003 FAX RECEIVED |
| Commissioner for Patents P.O. Box 1450 | JUL 0 7 2003 TECHNOLOGY CENTER 286 |

RESPONSE TO RESTRICTION AND ELECTION REQUIREMENTS

Sir:

This is in response to the Office Action dated June 5, 2003, imposing restriction and election requirements in the above-identified application.

| DIT | Ju | ily 7, 2003 | | |
|-----|---------|-----------------------------|-------------------|--|
| | (Dat | ily 7, 2003 c of Transmi | ission) | |
| | Jas | on M. Okun | | |
| 71 | | Attomey | for Applicants) | |
| MUN | r M. LL | | July 7, 2003 | |
| | mature | | Date of Signature | |